

# Room-temperature double quantum dot transistors for investigating Maxwell's Demon

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## Introduction

Maxwell's Demon (Fig. 1), a thought experiment proposing that energy may be transferred without the expenditure of work at the microscopic scale, suggests limitations on the 2<sup>nd</sup> law of thermodynamics. These limitations were refuted by Szilard [1], who considered entropy changes in the demon's "memory" to restore the 2<sup>nd</sup> law. Furthermore, Szilard proposed a one-molecule gas engine which has been used to identify the link between information and entropy, and extended to a quantum mechanical version by Zurek [2]. Recent advances in nano-fabrication have made it possible to experimentally investigate Szilard's engine and analyse changes in energy, entropy, and information in nano scale systems [3].

This paper shows that a single dopant atom double quantum dot (DQD) transistor operating at room temperature (RT) can form a Szilard engine. Device fabrication methods are shown, and RT charge stability diagrams are measured. Simulation of these diagrams is then used to investigate Szilard engine operation at RT.

## Fabrication and validation

- Silicon-on-insulator (SOI) wafer – (100) crystal orientation.
- Ultra-thin  $12 \pm 1$  nm top Si layer.
- Heavily-doped *n*-type  $\sim 10^{20}$  cm<sup>-3</sup> concentration of P.
- Point-contact region defined by electron beam lithography (EBL).
- Geometric oxidation of the point contact region produces a random array of dopant-atom (P) QDs.
- Gate voltages to tune array for DQD operation.

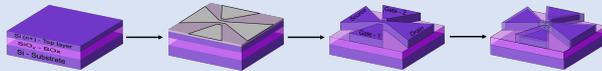


Figure 2. Fabrication sequence for a DQD system. From left to right: An SOI wafer with a bi-layer of PMMA is exposed by EBL, where device features are defined. Al evaporation is performed for reactive-ion-etching. Finally, geometric oxidation is performed to create tunnel barriers and isolate QDs.

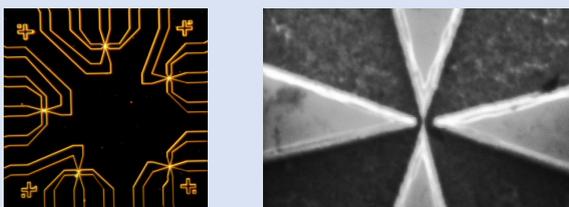


Figure 3 (Left) Dark field optical micrograph of the five DQD transistors with the nanostructure point-contact regions showing brightly. (Right) SEM image of a pre-oxidized single DQD transistor showing source-drain leads connected through a point-contact and two gates for electrostatic control.

## Configuration and electrical measurements

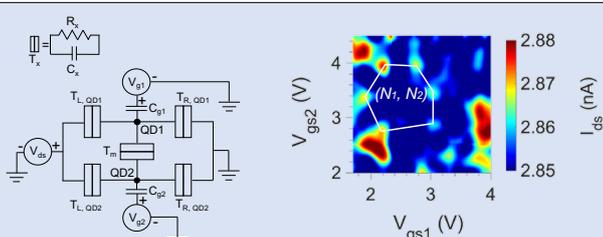


Figure 4. (Left) Circuit diagram for a parallel DQD. (Right) Experimental results of charge stability region showing signature DQD I-V characteristics. Current peaks form hexagonal patterns. Irregularities in shape correspond to DQD capacitance changes [4].

## Maxwell's Demon and Szilard's Engine

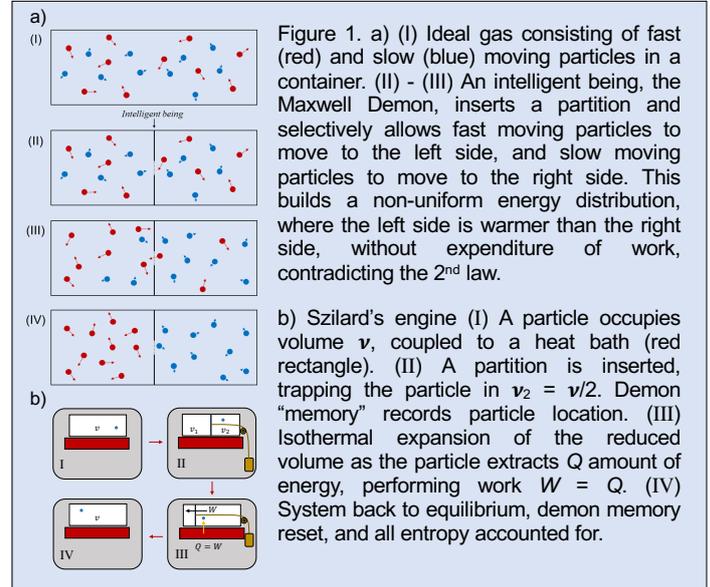


Figure 1. a) (I) Ideal gas consisting of fast (red) and slow (blue) moving particles in a container. (II) - (III) An intelligent being, the Maxwell Demon, inserts a partition and selectively allows fast moving particles to move to the left side, and slow moving particles to move to the right side. This builds a non-uniform energy distribution, where the left side is warmer than the right side, without expenditure of work, contradicting the 2<sup>nd</sup> law.

b) Szilard's engine (I) A particle occupies volume  $v$ , coupled to a heat bath (red rectangle). (II) A partition is inserted, trapping the particle in  $v_2 = v/2$ . Demon "memory" records particle location. (III) Isothermal expansion of the reduced volume as the particle extracts  $Q$  amount of energy, performing work  $W = Q$ . (IV) System back to equilibrium, demon memory reset, and all entropy accounted for.

## Monte Carlo simulation

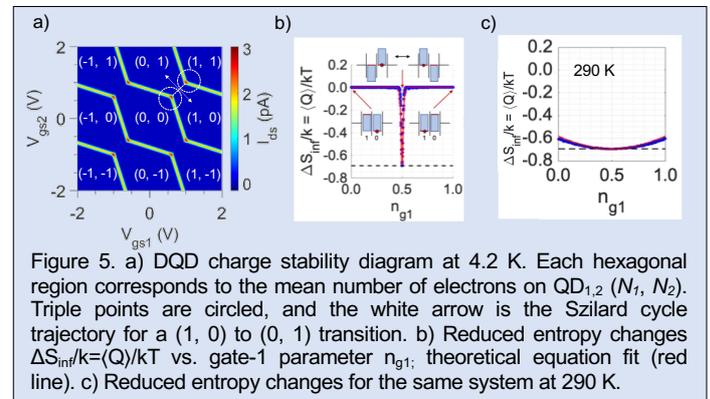


Figure 5. a) DQD charge stability diagram at 4.2 K. Each hexagonal region corresponds to the mean number of electrons on  $QD_{1,2}$  ( $N_1, N_2$ ). Triple points are circled, and the white arrow is the Szilard cycle trajectory for a (1, 0) to (0, 1) transition. b) Reduced entropy changes  $\Delta S_{inf}/k = (Q)/kT$  vs. gate-1 parameter  $n_{g1}$ ; theoretical equation fit (red line). c) Reduced entropy changes for the same system at 290 K.

## Conclusions

- RT operation of single dopant atom DQD transistors.
- Nano-fabrication of DQD transistors based on Si/SiO<sub>2</sub>/Si point-contacts in SOI material.
- RT measurements of charge stability diagrams.
- Gate voltage trajectories for one-electron gas Szilard engine operation.
- Extraction of entropy changes in the engine at RT.

## References

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